L Number	Hits	Search Text	DB	Time stamp
-	1	("4737823").PN.	USPAT	2004/06/09 11:54
-	1	("5026166").PN.	USPAT	2004/06/08 16:28
-	1	("5191200").PN.	USPAT	2004/06/08 16:29
-	1	("4356392").PN.	USPAT	2004/06/08 16:29
-	1	("4861162").PN.	USPAT	2004/06/08 16:29
-	1	("5414514").PN.	USPAT	2004/06/08 16:29
-	1	("4778275").PN.	USPAT	2004/06/08 16:29
-	1	("4251160").PN.	USPAT	2004/06/08 16:29
-	1	("5243195").PN.	USPAT	2004/06/08 16:30
-	9	(("4737823").PN.) (("5026166").PN.) (("5191200").PN.) (("4356392").PN.) (("4861162").PN.) (("5414514").PN.) (("4778275").PN.) (("4251160").PN.) (("5243195").PN.)	USPAT	2004/06/08 16:30
-	1	("5808742").PN.	USPAT	2004/06/08 16:57
-	2	5808742.URPN.	USPAT	2004/06/08 16:30
-	7	("4200395" | "4340305" | "4848911" | "5000573" | "5235408" | "5414514" | "5559598").PN.	USPAT	2004/06/08 16:31
-	19	5000573.URPN.	USPAT	2004/06/08 16:31
-	6	5751426.URPN.	USPAT	2004/06/08 16:32
-	5	("4710026" | "5000573" | "5114236" | "5142156" | "5550635").PN.	USPAT	2004/06/08 16:33
-	5	5585923.URPN.	USPAT	2004/06/08 16:34
-	19	5182610.URPN.	USPAT	2004/06/08 16:37
-	57	4200395.URPN.	USPAT	2004/06/08 16:39
-	10	4402610.URPN.	USPAT	2004/06/08 16:47
-	24	4779001.URPN.	USPAT	2004/06/08 16:48
-	16	4600309.URPN.	USPAT	2004/06/08 16:50
-	48	4631416.URPN.	USPAT	2004/06/08 16:52
-	21	4664524.URPN.	USPAT	2004/06/08 16:55
-	3	(grating same interfer$) same (overlay same latent)	USPAT; US-PGPUB	2004/06/08 16:58
-	9	(grating same interfer$) and (overlay same latent)	USPAT; US-PGPUB	2004/06/08 17:02
-	15	5783342.URPN.	USPAT	2004/06/08 17:00
-	31	(grating same interfer$) same overlay	USPAT; US-PGPUB	2004/06/08 17:02
-	8	((grating same interfer$) same overlay) and latent	USPAT; US-PGPUB	2004/06/08 17:07
-	361	(356/508,509,496).CCLS.	USPAT; US-PGPUB	2004/06/08 17:08
-	100	((356/508,509,496).CCLS.) and ((mask reticle photomask reticule) same (substrate wafer semiconduct$))	USPAT	2004/06/08 17:08

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–	67	(((356/508,509,496).CCLS.) and ((mask reticle photomask reticule) same (substrate wafer semiconduct$))) and (grating grate)	USPAT	2004/06/08 17:08
–	0	(("5808742").PN.) and (off near axis)	USPAT	2004/06/09 11:55
–	1	(("5808742").PN.) and axis	USPAT	2004/06/09 11:54
–	93	(off near axis) same (align$ same grating)	USPAT	2004/06/09 11:55
–	1	("5808742").PN.	USPAT	2004/06/09 13:06
–	1	((off near axis) same (align$ same grating)) same laten$	USPAT	2004/06/09 11:55
–	1	(("5808742").PN.) and filter	USPAT	2004/06/09 12:16
–	1	("5414514").PN.	USPAT	2004/06/09 12:31
–	0	((resist near mark) same (substrate near mark)) same (grating same overlay)	USPAT; US-PGPUB	2004/06/09 12:32
–	2	(($5resist same mark) same (substrate same mark)) same (grating same overlay)	USPAT; US-PGPUB	2004/06/09 12:37
–	5	(overlay same grating) same (((photomask mask reticle) near (grating mark target)) same ((wafer substrate) near (grating mark target)))	USPAT; US-PGPUB	2004/06/09 12:42
–	546	sugaya.in.	USPAT; US-PGPUB	2004/06/09 12:43
–	6	sugaya.in. and ((exposure near apparatus) and aberration)	USPAT; US-PGPUB	2004/06/09 12:44
–	2	overlay same (grating near (photoresist resist))	USPAT; US-PGPUB	2004/06/09 12:44
–	15	overlay and (grating near (photoresist resist))	USPAT; US-PGPUB	2004/06/09 13:01
–	203	overlay and (stage near (controller processor microprocessor computer))	USPAT; US-PGPUB	2004/06/09 13:02
–	5	(overlay and (grating near (photoresist resist))) and (overlay same grating)	USPAT; US-PGPUB	2004/06/09 13:03
–	3	(overlay and (stage near (controller processor microprocessor computer))) and (overlay same grating)	USPAT; US-PGPUB	2004/06/09 13:03
–	7	(overlay same align$) and (spectrometer same grating)	USPAT	2004/06/09 13:26
–	147	((align$ same mask) same overlay) and ((imag$3 project$ expos$3) same (overlay same (resist photoresist)))	USPAT	2004/06/09 13:29
–	182	((align$ same mask) same (wafer substrate semiconduct$)) and ((imag$3 project$ expos$3) same (overlay same (resist photoresist)))	USPAT	2004/06/09 13:34
–	8	((align$ same mask) same (wafer substrate semiconduct$)) and ((imag$3 project$ expos$3) same ((overlay near mark) same (resist photoresist)))	USPAT	2004/06/09 13:34
–	2202	(356/399-401).CCLS.	USPAT; US-PGPUB	2004/06/09 13:45
–	3091	(355/53,55).CCLS.	USPAT; US-PGPUB	2004/06/09 13:45
–	5214	(430/5,22,30).CCLS.	USPAT; US-PGPUB	2004/06/09 13:45
–	985	(250/548).CCLS.	USPAT; US-PGPUB	2004/06/09 13:45
–	155	((356/399-401).CCLS.) and (overlay same (grating mark$ target))	USPAT; US-PGPUB	2004/06/09 13:46
–	111	((355/53,55).CCLS.) and (overlay same (grating mark$ target))	USPAT; US-PGPUB	2004/06/09 13:46
–	191	((430/5,22,30).CCLS.) and (overlay same (grating mark$ target))	USPAT; US-PGPUB	2004/06/09 13:46
–	32	((250/548).CCLS.) and (overlay same (grating mark$ target))	USPAT; US-PGPUB	2004/06/09 13:46

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